



Properties of Interfaced Materials and Films

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Deadline for manuscript
submissions:

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Message from the Guest Editors

This Special Issue will focus on electrical, electronic, and microscopy characterization techniques revealing the mechanics of stress formation at grain boundaries as well as other techniques that are necessary to understand evolution in surfaces and interfaces. Relevant parameters of studies will be the depth of stress fields and their effect on bandgap and their elastic and plastic limits before forming dislocations. This Special Issue also aims at correlating these interfacial stress and strains mechanics with the observed electrical, electronic, and optical properties and to understand their influence on carrier mobility, carrier confinement, and bandgap modulations. It is our pleasure to invite you to submit a manuscript on the topic. Full papers, communications, and reviews are all welcome.

Keywords

- evolution of interfaces
- lattice matching
- interface chemistry
- misfit dislocations
- semiconductors
- metals
- insulators
- tunneling mechanisms
- microscopy–AFM, STEM, TEM
- heterostructures
- devices





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Message from the Editor-in-Chief

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